

# Student Program: ICOM-CC 2026 Sponsorship

## Overview

Bev/Art is committed to the future of heritage conservation, and that includes supporting the people who will carry the field forward. This year, we're launching a program for graduate-level students in archives, libraries, museums and related conservation disciplines as they take their first steps into professional practice.

The program begins with a partnership we're especially proud of: the International Council of Museums Committee for Conservation Triennial Conference, being held 14-18 September in Oslo, where Bev/Art is headquartered. We will sponsor two students to attend through a collaboration with the host committee at Nasjonalmuseet — selected students will receive conference admission and accommodations.

## Eligibility Requirements

To apply, you must:

- Be a current graduate student or recent graduate (within one year) studying conservation — including but not limited to objects, paintings, textiles, paper, photography, archaeology or architectural conservation
- Be available to travel to Oslo for the conference dates (Sept. 14-18 2026)
- Be able to cover the cost of travel to and from Oslo
- Be willing to participate in interviews for Bev/Art and ICOM-CC social media and blogs
- Submit your essay in English (essays must be written by you, not AI)

## How to Apply

Apply at <https://www.bev.art/icomcc-2026/student-sponsorship>

Submit a written essay (500-750 words) addressing the following:

- Why do you want to attend this conference?
- What do you hope to learn or gain from attending?
- How would this experience impact your studies or early career in conservation?

## Selection Criteria

We're looking for essays that demonstrate genuine interest in conservation and personal motivation for attending this specific opportunity. Strong applications will show thoughtfulness and self-awareness about how the conference fits into your development as a conservator.

We welcome all levels of English proficiency and understand that many applicants will have English as a second language.

We particularly encourage applications from students who face financial or structural barriers to attending independently and those who would benefit from expanded professional exposure and networking opportunities.

## Application Window

Submissions will be accepted beginning 23 February through 11:59 CET on 30 March.